

Title: APPARATUS AND METHOD FOR CLEANING AT LEAST ONE PROCESS CHAMBER FOR COATING
AT LEAST ONE SUBSTRATE
Inventors: Klaus Kallee and Ronald Hepper
Docket No.: 16056.13

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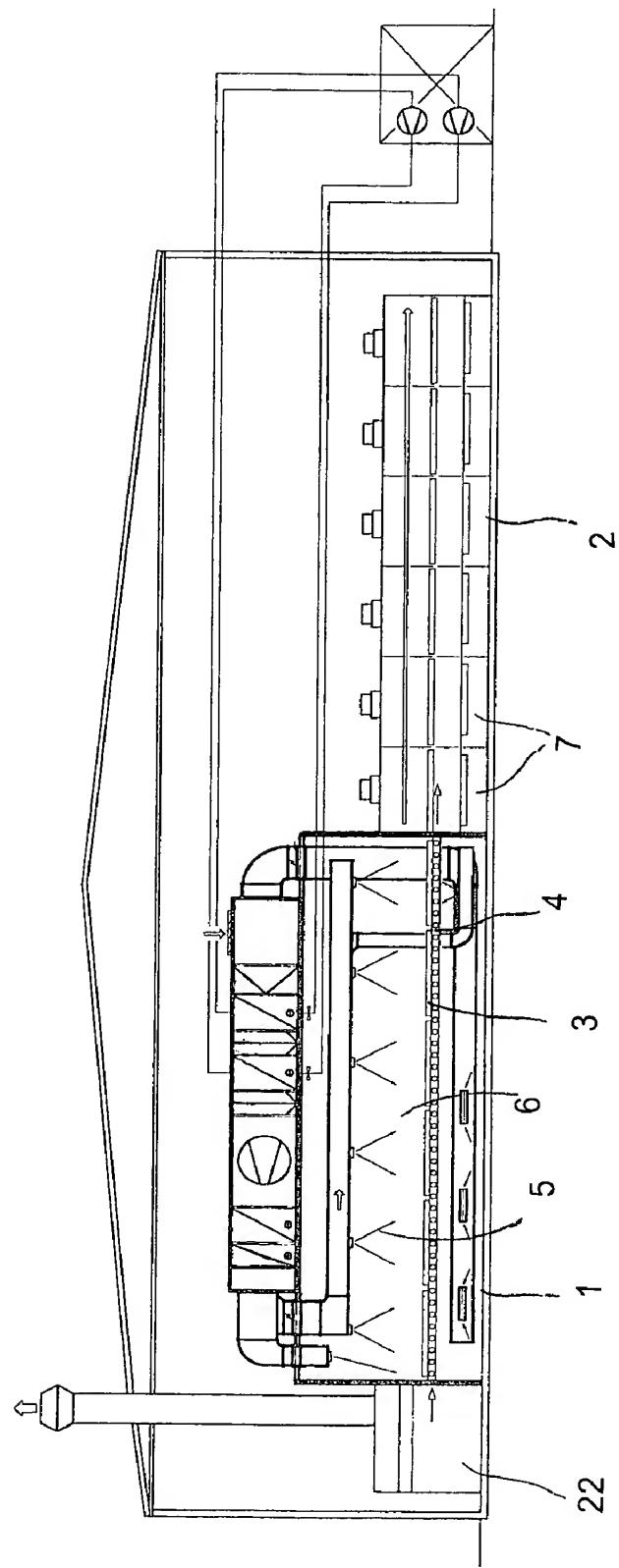


FIG 1

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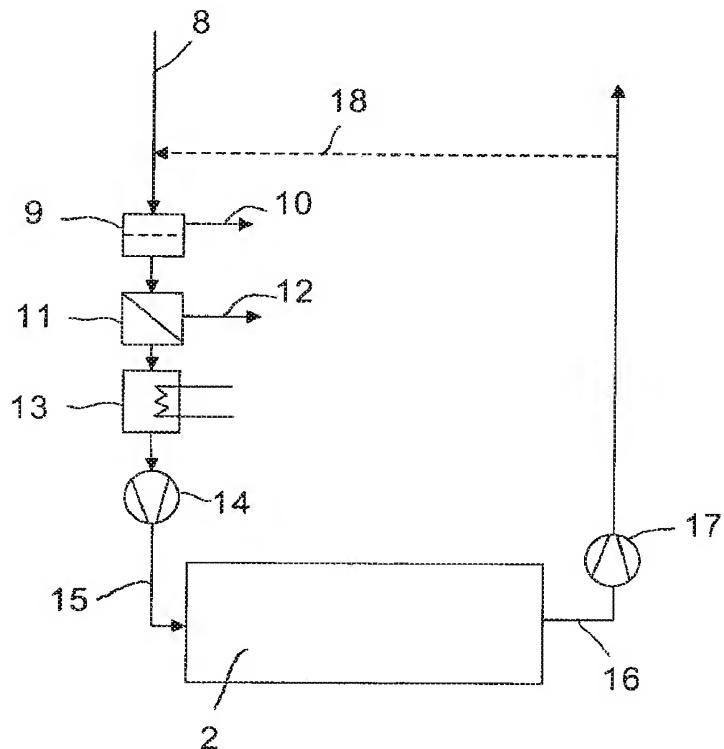


FIG 2

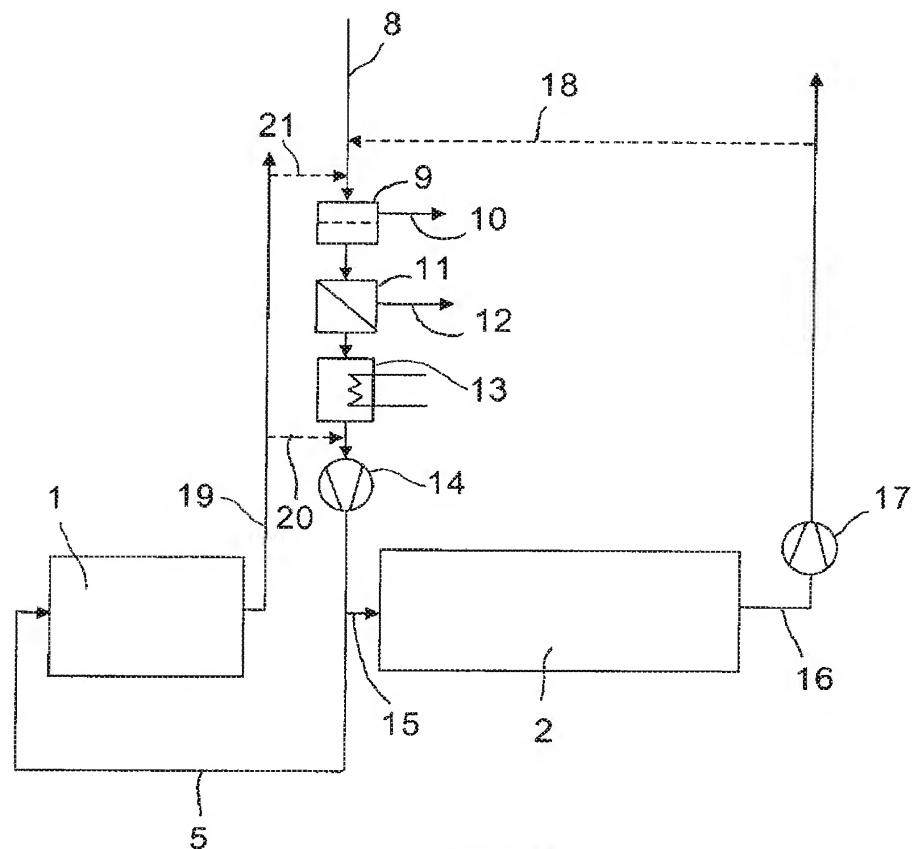


FIG 3

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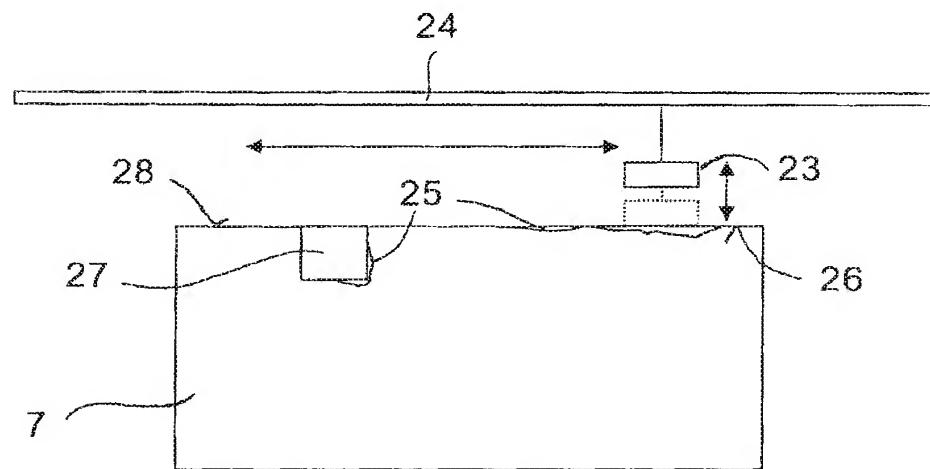


FIG 4